Design, Manufacturing and Test of a High-Precision MEMS Inclination Sensor for Navigation Systems in Robot-Assisted Surgery

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Abstract: Robot supported minimally invasive interventions are state of the art in operating theatres. To increase the accuracy of surgical instrument positioning, high-precision motion tracking systems are required. The miniaturization of microelectromechanical systems (MEMS) facilitates the placing of orientation detection sensors close to the mounting of the surgical instrument to enhance positioning accuracy. A high resolution inclination sensor was developed using the innovative approach of laser-micro-welding. Trench sizes down to 800 nm are fabricated with more than 6-fold increase in aspect ratios (structure depth to electrode gap) compared to sensors without gap reduction. Electrical and physical tests as well as finite-element-simulations were performed. An increased sensitivity from 7.2 fF/° up to 60 fF/° was verified for the sensor with reduced electrode gap and a customized ASIC.

Keywords: Surgical Robot Navigation, Inertial Sensor, Inclination Sensor, Microelectromechanical System (MEMS), Gap Reduction

1. Introduction

In the past few years surgical robots firmly established to support surgeons in minimally invasive interventions. One benefit of the usage of robots in medicine is the ergonomic posture of the surgeon that eases high concentrated operating especially over a long time. Additionally the physical presence of high specialized surgeons in the operating theatre is technically no longer necessary since 2002. This was demonstrated by New York surgeons who realized a remote robot-assisted laparoscopic removal of the gallbladder of a patient in Strasbourg with the ZEUS System (Computer Motion, Galeta, CA) [1]. In 2013, about 85% of radical laparoscopic prostatectomies were realized robot-assisted in the USA and it is foreseeable the rate will still increase [2].

Fields of application beside the biopsy and resection of tumours are the locally limited high-dose irradiation, brain and abdominal surgery as well as cardiac surgery, in summary all precise navigation tasks. Major advantages of these systems are the possibility to scale down the hand movement of the surgeon to high-accuracy fine pitched motions of the surgical instruments, the precise locking mechanism and tremor cancellation of the surgeon’s steering movements [3]. Consequently, unintentional injury of healthy tissue, blood vessels or nerves can be prevented.

2. Aim

To achieve very accurate instrument positioning, high-precision motion tracking systems are essential to get for example the actual tilt of an endoscope. Due to miniaturization of MEMS, the placing of orientation
detection sensors close to the endoscope is possible. Furthermore, the integration of MEMS tilt sensors into the surgical instrument near the mounting can facilitate the measurement of vibrations and their compensation. The developed capacitive MEMS sensor complies with the requirements of small size and high-precision inclination measurement.

3. Methods

3.1. Fabrication Technique

The sensor is fabricated by using silicon high aspect ratio micromachining (HARM) technology to achieve 50 µm thick structures with about 4.5 µm trench size [4]. The performed process flow of the technology is presented in Figure 1. This technology starts with the deposition and the patterning of the insulation layer on highly p-doped single crystalline Si-Wafer (a). Subsequently, aluminium is sputtered and patterned as interconnection layer (b). Afterwards the silicon microstructures were etched via a silicon dioxide mask in a STS Multiplex ICP System by deep reactive ion etching (DRIE) (c). The deposition of the passivation layer, the spacer etching, and the isotropic etching for releasing the movable structures is performed in situ with the DRIE (d). After removal of the sidewall passivation, the AIM specific interconnection beams were undercut by an isotropic etching process (e). Finally the silicon dioxide layer used as the mask for DRIE is removed (f). Due to the isotropic plasma etch step after the DRIE the electrode gap is widened, which affect the aspect ratio (structure depth to electrode gap) and thereby the sensitivity of the MEMS. The sensitivity of capacitive inertial sensors is highly influenced by the capacitance gradient due to an electrode movement. To increase the capacitive gradient, the aspect ratio of the vertical comb electrodes should be increased. However, fabrication restrictions limit the minimum distance between the electrodes. Therefore, the reduction of the trench width after patterning of the microstructures has been proposed and revealed. The fabrication of sub-micron trenches [5-10] or structures with very high aspect ratios up to 100 [6] is advantageous for many applications. To increase the aspect ratio of the sensing electrode gap, different technologies for reduction of trench width of capacitive micro structures below the technological limitations have been proposed and demonstrated in recent years [11-15].

For post-process technologies electrostatically [11, 13] and thermally [12] actuated gap reduction mechanisms have been presented. The permanent application of a voltage for locking the mechanism in its final position is not energy-efficient and possibly influences the transducer signals. Using ratchet structures or bistable mechanisms for locking the reduced gap are critical for the reliability of the transducers. An in-process gap reduction approach [14] utilizes residual stress in microstructures, coated with silicon dioxide. However, the technique causes a high temperature sensitivity of the microstructures. Furthermore the silicon micro-welding process [15] seems to be reliable but has a need of large mechanisms, which enlarges the chip size dramatically. In this work a high-resolution tilt sensors was developed, utilizing the innovative approach of laser-micro-welding [16], to enable high aspect ratios up to 100 for trench sizes down to 800 nm after fabrication. The novelty is due to the use of a differential capacitor design, which greatly complicates the reduction of the electrode gap, but with the advantage of higher linearity and sensitivity compared to single capacitor.

![Figure 1. Schematic process flows of the technology: a) deposition and patterning of insulating layers b) deposition and patterning of conducting layers c) DRIE of silicon d) release etching of silicon e) isotropic etching for release of interconnection beams f) removal of oxide mask.](image1)

![Figure 2. Schematic picture of MEMS differential capacitor working principle with gap-reduction mechanism and equivalent circuit.](image2)
A post process gap reduction mechanism, based on the separation of the seismic mass into two symmetrical parts (Figure 2) was integrated in the MEMS layout. After all critical MEMS process steps the two initially separated sides of the differential capacitor were connected by using the electrostatic force of the sense comb electrodes (Figure 3). In initial position the two separated seismic masses have an electrode gap of about 4.5 µm, which can be easily fabricated using standard DRIE etching processes. The electrostatic force necessary to connect the masses is generated by a small mismatch of the gaps. The fixation was achieved by adhesive bonding of overhanging aluminum layers in the bonding zone and partly welding due to a briefly high current. Long-term stability and reliability after the first fixation step was ensured by laser-micro-welding on the aluminium layers (see Figure 4). For the welding process was performed on a laser micro treatment facility [17], consisting of a femtosecond laser and a galvanometer scan system for high accuracy beam deflection and focusing.

Figure 3. SEM picture of the AIM-MEMS with the gap reduction mechanism. a) without pull-in voltage (initial gap) and b) with applied pull-in voltage, which results in minimized electrode gaps and connected seismic masses.

Figure 4. SEM image of the laser-micro-welded area and the reduced electrode gaps of the tilt sensor.

3.2. Sensor Design

To determine design parameters finite element (FE) simulations were implemented especially taken the gap reduction process into account. Therefore, an ANSYS® FE full model perturbation analysis was performed to design the mechanical system considering the preload of the springs due to the gap reduction mechanism. In Figure 5 the full mechanical FE model including all components like electrodes, anchor mass and spring is presented.

Figure 5. Component view of the full mechanical FE model of the sensor structure.

A design study of the electrode combs has been done using parameterized Computational Fluid Dynamics (CFD) simulations to optimize the damping behaviour for the 800 nm reduced gap. Input parameters of the CFD model were the ambient air pressure \( p \), which highly influences the damping coefficient of the system, as well as the oscillation amplitude \( s \) and the electrode overlap length. The pressure range is 1 kPa to 100 kPa due to the possibility of evacuating the encapsulated system. The oscillation amplitude \( s \) can be set up to a maximum of 300 nm. The damping coefficient was determined on several interpolation points with the help of CFD simulations of a single electrode comb cell. Considering the entire comb capacitor, translational periodicity conditions were used on the outer walls where the air can stream from one cell to another together with a simple multiplication of the damping coefficient with the total number of comb cells. The interpolation points are fitted with the least-square method within a Matlab® script to the polynomial function \( b(s, p) \) of the damping constant. In Figure 6 the result of the fit for an overlap length of the electrodes of 10 µm can be seen.

The damping coefficient from CFD was used in a harmonic FE analysis on the full mechanical sensor model to estimate the upper and lower design limits resulting from fabrication technology tolerances (see Figure 7).
4. Results

All Measurements on the performance of the entire sensor system were carried out on the test setup shown in Figure 8. Stacking of the ASIC and sensor chips was used on top of a thermoplastic thermal compensation structure designed to minimize the stress impact due to a temperature gradient and thus minimize the thermal drift of the device.

Using the post-process technology of laser-micro-welding, the aspect ratio of the electrode gaps is increased from initially 15 to 90. Furthermore, the stability and the reliability of the welded connections were confirmed by a long-term analysis.

Results of the parameterized CFD analysis of the comb electrode show that the damping coefficient is underrated by at least 30% compared to analytical methods [18], which emphasizes the importance of the damping simulations (see Figure 6). This is due to the fact that the analytical equations are only valid for relatively large gaps where continuum conditions can be assumed, but not for sub-micron gaps.
Electrical and physical tests of the sensor without gap reduction were performed. The differential capacitance over tilt angle $\alpha$ was measured in a range from $-40^\circ$ to $40^\circ$ (see Figure 9). Due to the measurements the sensitivity of the sensor without gap reduction is with 7.2 fF/$^\circ$ lower compared to the calculated value from the first design. A uniform structure thickness is achieved by thinning of the active wafer before patterning. The nominal thickness value used in the design was 50 µm, though the characterization of the processed structure shows that the thickness after thinning is only around 40 µm which leads to a lower sensitivity and fits to the simulations. Besides the effect of linearization around the angle $\alpha = 0^\circ$, another advantage of the differential capacitor is the increase in sensitivity by the factor of 2 compared to single capacitor arrangements.

With the matched design parameters the design procedure could be validated and a sensitivity of at least 60 fF/$^\circ$ for the improved sensor with gap reduction can be proposed (see Figure 10). Compared to real sensor data the maximum error of the amplitude response up to the working range of 1 kHz is only around 1% (see Figure 7).

**5. Conclusion**

In this paper, a high-precision capacitive MEMS tilt sensor was designed for application in precise orientation measurements. The inclination sensor was fabricated using laser-micro-welding and a gap reduction mechanism on differential capacitor arrangement to improve the sensitivity of the device. Measurements on the real system verify the developed FEM design model. Scheduled measurements on the sensor with reduced gap are outstanding but very promising. The sensitivity of the device can be improved by a factor of at least 8 compared to a standard sensor without gap reduction, making it well suitable for highly accurate navigation tasks in robot-assisted surgery.

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